OHMI et al.

678,741

Serial No. 个 Series Code 个

October 4, 2000 Filed: Hon. Commissioner of Patents

Washington, D.C. 20231

Sir:

Inventor(s):

Appln. No.:

## REPLY/AMENDMENT/LETTER

**Group Art Unit** 

Examiner:

Appln. Title:

Atty. Dkt.

Crowell, Anna M. EL00009CDC

P 274025

**Client Ref** PLASMA PROCESSING APPARATUS

February 6, 2003 Date:

This is a reply/amendment/letter in the above-identified application and includes the herewith attachment of same date and subject which is incorporated hereinto by reference and the signature below is treated as the signature to the attachment in absence of a signature thereto.

FEE REQUIREMENTS FOR CLAIMS AS AMENDED 1. Small Entity claim **Fee Code** Large/Small Entity **Additional Present Extra** For B & C **Highest number** Claims A. X NOT made Fee See Required remaining after previously paid for B. Withdrawn Lg/Sm Separate Paper amendment C. made herewith (Pat-256) D.  $\square$  made previously 103/203 + \$0 x \$18/\$9 =35 \*\*minus 0 35 2. Total Effective Claims 102/202 + \$0 x \$84/\$42 = \*\*\*minus 3. Independent Claims 4. If amendment enters proper multiple dependent claim(s) into this application for first + \$0 + \$280/\$140 = 104/204 time (leave blank if this is a reissue application) ...... add NONE February 6, 2003 5. Original due Date: 115/215 \$110/\$55 = 6. Petition is hereby made to extend the original due (1 mo)116/216 + \$0 \$410/\$205 = date to cover the date this response is filed for which the (2 mos) 117/217 \$930/\$465 = (3 mos) requisite fee is attached 118/218 \$1,450/\$725= (4 mos) 128/228 \$1,970/\$985= (5 mos) 7. Enter any previous extension fee paid since above original due date and subtract - \$0 + \$0 **Extension Fee** 8 148/248 + \$0 + \$110/\$55 9. If Terminal Disclaimer attached, add Rule 20(d) official fee ..... 126 + \$180 + \$0 126 + \$180 or if Rule 97(d) Request ...... add 146/246 + \$0 + \$750/370 11. After-Final Request Fee per rules 129(a) and 17(r) ..... + \$0 149/249 x \$750/375 ea 12. No. of additional inventions for examination per Rule 129(b)..... 1179/1279 + \$0 + \$750/375 13. Request for Continued Examination (RCE) ..... + \$0 14. Petition fee for **TOTAL FEE = \$0** 15. 16. \*If the entry in this space is less than entry in next space, the "Present Extra" result is "0". **PLEASE CHARGE** 

17. \*\*If the "Highest number previously paid for" in this space is less than 20, write "20" in this space.

18. \*\*\*If the "Highest number previously paid for" in this space is less than 3, write "3" in this space.

**OUR DEP. ACCT** Our Deposit Account No. 03-3975) (Our Order No. 40258 274025

CHARGE STATEMENT: The Commissioner is hereby authorized to charge any fee specifically authorized hereafter, or any missing or insufficient fee(s) filed, or asserted to be filed, or which should have been filed herewith or concerning any paper filed hereafter, and which may be required under Rules 16-18 (missing or insufficiencies only) now or hereafter relative to this application and the resulting Official Document under Rule 20, or credit any overpayment, to our Accounting/Order Nos. shown above, for which purpose a duplicate copy of this sheet is attached.

This CHARGE STATEMENT does not authorize charge of the issue fee until/unless an issue fee transmittal sheet is filed.

Query: Is appeal deadline now? If so, file Notice of Appeals separately.

Pillsbury Winthrop LLP Intellectual Property Group

P.O. Box 10500 McLean, VA 22102 Tel: (703) 905-2000

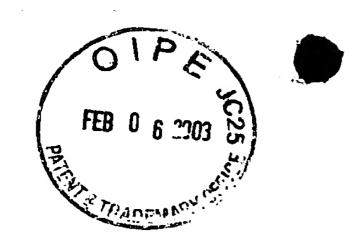
Glenn J. Perry By Atty:

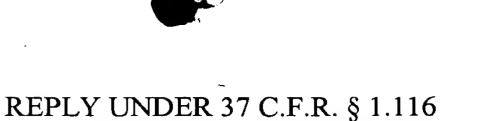
Sig:

Reg. No. 28,458

(703) 905-2500 Fax: (703) 905-2161 Tel:

Atty/Sec: GJP/EED NOTE: File this cover sheet in duplicate with PTO receipt (PAT-103A) and attachments





**EXPEDITED PROCEDURE** 

**TECHNOLOGY CENTER ART UNIT 1763** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION OF

Confirmation No.: 9698

OHMI et al.

Group Art Unit: 1763

Appln. No.: 09/678,741

Examiner: CROWELL, ANNA M.

Filed: October 4, 2000

Title: PLASMA PROCESSING APPARATUS

#IIBME NW 2/12/03

February 6, 2003

## RESPONSE AFTER FINAL UNDER 37 C.F.R. § 1.116

Hon. Commissioner of Patents Washington, D.C. 20231

Sir:

RECEIVED
RECEIVED In response to the Office Action dated November 6, 2002, please amend the aboveidentified application as follows:

## IN THE CLAIMS

Please enter the following amended claims:

- (Twice Amended) A plasma processing apparatus for applying a process to a substrate 1. to be processed, the plasma processing apparatus comprising:
  - a chamber of which interior can be depressurized,
- a gas supply system constructed and arranged to supply a gas to the chamber and an exhaust system configured and arranged to exhaust the gas supplied to the chamber and to depressurize the chamber;
- a part of a wall constituting the chamber being a flat plate dielectric material plate formed of a material which passes a microwave therethrough substantially without a loss;